

Index

- Aerosol deposition methods 205
 α -Al₂O₃(0001), iron oxide on
 – case study 33
 Alkali metals, ionization potentials of 85
 Alternative transparent conductors 226–28
 Aluminum oxide compounds 240
 Angle-resolved photoemission spectroscopy
 (ARPES) 188
 Anodic and coloring under ion extraction 233
 Anodic oxidation 312
 Anodization 320
 Antibacterial capacity 320–21
 Artificially layered Ferroelectrics 291–95
 Atomic force microscopy (AFM) 30–31, 130
 Atomic layer deposition (ALD) process 6,
 15–16, 110
 Atomic oxygen 49
 Au/MgO surface, model of 158
 Au₁₈ cluster 168
 Au₂₀ on MgO films 82–83
 Austenitic alloy 124

 Back-gated FEDs 195
 Band gap with film thickness, evolution
 of 77–79
 Barium fluoride 206
 Benefit of plant (BOP) 203
 Bismuth strontium calcium copper oxide 239
 Blyholder model 155
 Bone–implant contact (BIC) values 320
 Born effective charge 274
 Bottom-up technique 331
 Bovine serum albumin (BSA) 316
 Branched In₂O₃ nanowires, growth processes
 of 333
 Brønsted–Evans–Polanyi (BEP) 165
 Bulk hafnia 106
 Bulk metal oxides, electrical
 behaviors of 77

 Bulk structures, growth of 63–68
 Buried oxide layers 20–21
 Burstein–Moss effect 224

 Calcium fluoride 206
 Catalysis 75–76
 Catalysis by gold 154–63
 Cathodic and coloring under ion
 insertion 233
 Ce_{0.9}Gd_{0.1}O_{1.95} (CGO) 214
 CeO₂ films on Ru 154 164
 CeO₂(111)/Pt(111), case study 30
 CeO₂, ultrathin films of 12
 Cerium oxide (CeO₂) films 153
 Characterization tools of ultrathin oxide
 films 27–43
 – spectroscopic techniques 36–43
 – – conversion electron Mössbauer
 spectroscopy (CEMS) 41–43
 – – magneto-optical Kerr effect
 (MOKE) 40–41
 – – X-ray magnetic circular/linear
 dichroism 36–40
 – structure determination techniques 28–36
 – – noncontact atomic force microscopy
 (NC-AFM) 30–31
 – – photoelectron diffraction 35–36
 – – scanned probe microscopy (SPM) 28
 – – scanning tunneling microscopy 28–30
 – – surface X-ray diffraction (SXRD)
 33–35
 – – X-ray photoemission electron microscopy
 (X-PEEM) 31–33
 Charge transfer. *See* Electronic transport
 through oxide ultrathin films
 Charged coupled device (CCD)
 sensors 246
 Chemical bonding contributions to electrical
 boundary conditions 285–87

- Chemical methods of preparation of oxide ultrathin films 14–19
 - chemical vapor deposition 15–16
 - liquid-precursor-based thin-film deposition techniques 16–19
- Chemical sensors 243
- “Chemical switching” 284
- Chemical vapor and electrochemical vapor deposition method (CVD/EVD) 203
- Chemical vapor deposition 15–16
- Chemisorption 250, 338
- Chromium 124
- Chromogenic materials 223
- CO adsorption on gold 159
- CO oxidation on FeO/Pt 171
- Cobalt oxide films 67–68
- Color centers 151
- Colossal magnetoresistance (CMR) 184
- Combined heat and power (CHP) 201
- Complementary
 - metal–oxide–semiconductor (CMOS) 102, 246, 259
 - “Compression” effect 87
- Computed optical data, for ITO films 225–26
- Conductometric sensors 336–40
- Controlled oxidation of bulk single-crystal surfaces 7–8
- Conventional ion implantation 315
- Conversion electron Mössbauer spectroscopy (CEMS) 41–43
 - Fe₃O₄(111)/Pt(111), case study 43
- Copper 122–23, 126–28
- Cr(III)-rich passive films, aging effects
 - on 136–37
- Crystal truncation rods 33
- Crystalline silica films 13
- Cu(I) and Cu(II)/Cu(II) passive films 131–33

- Density functional theory (DFT) 31, 77, 105, 119, 266
- Detachable ultrathin oxide films 19–20
- Devonshire–Ginzburg–Landau (DGL) phenomenological theory 269–70, 273
- Domain morphology 289–90
- Domain walls 290–91
- Drude model 225
- Drug-eluting cardiovascular stent (DES) 321

- EC foils by roll-to-roll manufacturing 234–35
- EC oxides 233
- “Effective medium theory” 231
- Elastic strain 4
- Electrical functionals, with depolarization field 284–85
- Electrical gas sensors 250–54
- Electrochemical modification 312
- Electrochromics 223, 232–35, 232–33
 - EC foils by roll-to-roll manufacturing 234–35
 - nanostructural features, of EC films 233–34
- Electron paramagnetic resonance (EPR) experiments 79
- Electron-bombarded MgO/Mo, gold clusters deposited on 162
- Electronic structure theory 77
- Electronic transport through oxide ultrathin films 79–85
- Electrostatic coupling 291–93
- Energy versus Ni–Ni spacing 54
- Exfoliated oxide nanosheets 19

- F²⁺center 151
- Fabrication of oxide nanostructures 48–49
- Fabrication, basic aspects of 3–7
- Fe(II)/Fe(III) passive films 135–36
- Fe/NiO/MgO(001) and Fe/NiO/Ag(001), case study 40–41
- Fe_{3–δ}O₄(111) ultrathin films on Pt(111), case study 38–39
- Fe₃O₄(111)/Pt(111), case study 43
- Fe–BTO interfaces, magnetoelectric coupling at 196–97
- FeO/Pt system 172
- Ferritic alloy 124
- Ferroelectricity
 - artificially layered 291–95
 - – electrostatic coupling 291–93
 - – engineering at interfaces 293–95
 - basic definitions 266–69
 - modeling in oxides 274–77
 - polarization domains, morphology and functional properties of 287–91
 - – domain morphology 289–90
 - – domain walls 290–91
 - – Kittel law 287–89
 - theoretical methods 266–69
 - – Devonshire–Ginzburg–Landau (DGL) phenomenological theory 269–70
 - – first-principles simulations 270–72
 - – second-principle methods 272–74
 - theory of 277–87
 - – chemical bonding contributions to electrical boundary conditions 285–87
 - – electrical boundary conditions 280–84
 - – electrical functionals, with depolarization field 284–85
 - – mechanical boundary conditions 277–80

- in ultrathin-film capacitors 265–96
- Ferromagnetic (FM) metals 181
- Ferromagnetic materials 240
- Field effect devices (FEDs) 195
- Field-emission resonance (FER) 148–49
- Filopodia 316
- First-principles simulations, in ferroelectricity
 - theoretical methods 270–72
- (533)-oriented NiO periodic model 139
- Fixed charge 106
- Flexibility of oxide thin films
 - and polaronic distortion 94–97
- Flexoelectricity 280
- Fourier transform infrared
 - spectroscopy 310
- Frequency-modulated dynamic force
 - microscopy (FM-DFM) 151
- Fuel cells, types of 202

- Gadolinium-doped CeO₂ (GdDC) 210
- Gas sensor system 339
- Gas sensors 247–54
 - applications for 248
 - electrical 250–54
 - mass sensitive 249–50
 - optical 248–49
- Gate dielectric films, theoretical modeling
 - of 104–6
 - aims of 104–5
 - computational methods 105–6
- Giant magnetoresistive (GMR) sensors 243
- Ginzburg–Landau theory 269
- Gold metal nanoparticles 167
- Gold, potential energy profiles for 90–91
- Graphene 227
- Grazing incidence X-ray diffraction (GIXD)
 - experiments 130
- Growth mechanisms 331

- Hafnia 106
- Hafnium ions 107
- Half-metallic manganites 183–89
- Heterostructures, longitudinal 333
- HfO₂ films
 - oxygen vacancies in 106
- HfO₂ gate dielectric films, structure and
 - properties of 106–10
 - *k* value in HfO₂, 108–9
 - oxygen-deficient defect centers in
 - bulk 106–7
 - self-trapped polarons in 107–8
 - Si/SiO₂/HfO₂ films and interfaces
 - 109–10
- High-*k* dielectrics 101

- Human skeletal mesenchymal stem cell
 - (hMSC) 317
- Hydroxyl groups, in catalysis 156
- Hydroxylated and pristine MgO films
 - CO adsorption on 158
 - gold deposits on 160
- Hydroxylated MgO, gold particles on 160

- Imperfect screening 280–84
- In₂O₃ films 253
- Ion implantation 315, 319
- Ion scattering spectroscopy (ISS) 122
- Ionosorption 335
- Ion-selective field effect transistor (ISFET)
 - sensors 246, 247
- Iron 124
- Iron oxide films 14
- Iron oxide, growth of 64
- Iron oxide on α -Al₂O₃(0001),
 - case study 33

- Jahn–Teller effect 184

- K* value in HfO₂, 108–9
- Kelvin probe force microscopy 89
- Kerr effect 40
- Kerr effect, magneto-optical
 - Fe/NiO/MgO(001) and Fe/NiO/Ag(001),
 - case study 40–41
- Kittel law 287–89
- Kohn–Sham energies 77

- La_{0.5}Sr_{0.5}CoO₃ (LSCO) 214
- La_{0.8}Sr_{0.2}Ga_{0.8}Mg_{0.2}O₃ (LSGM) 208, 210
- La_{2/3}Sr_{1/3}MnO₃ (LSMO) films
 - proximity and electric field effects on
 - magnetic properties of 189–96
- La_{2/3}Sr_{1/3}MnO₃ (LSMO) films 181, 183
- Lamellipodia 316
- Large-scale coalescence (LSC) 227
- Leakage current 106
- Liquid-precursor-based thin-film deposition
 - techniques 16–19
- Lithium niobate (LiNbO₃) 239
- Lithium-doped silica 92–94
- Lithographic techniques 334
- Local relaxations 94
- Low-energy electron diffraction
 - (LEED) 27

- Magnesium doping of VO₂, 231–32
- Magnesium single crystals, oxidation of 7
- Magnetic sensors 243–46
- Magnetic tunneling junctions (MTJs) 182

- Magnetization, electric control of
 - in oxide heterostructures 189–97
 - – LSMO films, proximity and electric field effects on magnetic properties of 189–96
 - – magnetoelectric coupling at Fe–BTO interfaces 196–97
- Magneto-optical Kerr effect
 - Fe/NiO/MgO(001) and Fe/NiO/Ag(001), case study 40–41
- Magneto-optical Kerr effect (MOKE) 40–41, 187
- Magnetron sputtering 8
- Manganese oxidation state (Mn OS) 192, 193
- Manganese oxide on Pd surface 55, 59
- Mass-selective ion implantation 315
- Mass-sensitive gas sensor 249–50
 - basic principles of 249
- Metal-induced gap states 86
- Metal–insulator–metal (MIM) tunneling diode 246
- Metal-organic chemical vapor deposition (MOCVD) 15
- Metal oxide (MOX) film-based gas sensors
 - sensing principle of 250
- Metal oxide chemical sensors 335–36
- Metal oxide gas sensors, gas-sensing mechanisms of 251–54
 - receptor function 252
 - transducer function 252
 - utility function 252
- Metal–oxide hybrid systems 47, 48
- Metal–oxide interface 53
- Metal–oxide–metal (MOM) diodes 246
- Metal oxide nanowires, for new chemical sensor devices 329–41
 - conductometric sensors 336–40
 - integration 334–35
 - metal oxide chemical sensors 335–36
 - optical sensors 340–41
 - synthesis 331–34
- Metal oxides and pH response 247
- Metal–oxide–semiconductor (MOS) 240
- Metal–oxide–semiconductor field effect transistors (MOSFETs) 1, 108
- Metal-supported oxide phases, dimensionality of 58–63
- Metal surfaces, ordered oxide nanostructures on 47–69
- MgO films
 - charge transfer through 81–82
 - on Mo 146–47
- MgO thin films, growth of 78–79
- MgO/Ag film 150
- Mixed oxide films 153
- Mn₃O₄ on Pd surface 56
- MnO₂ nanowires on a Pd(1 1 17) surface 61
- Model Hamiltonian 272–73
- Model systems 145
 - classes of 146
- Molecular beam epitaxy (MBE) 4, 188
- Molecular oxygen
 - exposure to 5
 - as oxidizing agent 48
- Monoclinic hafnia 106
- Monoclinic zirconia 106
- Monolayer catalysts 163
- MOS-based photodetectors 246
- Mössbauer effect 41–43
- Mössbauer spectroscopy, conversion electron
 - Fe₃O₄(111)/Pt(111), case study 43
- Multiferroics (MFEs) 196
- Multiphonon trap-assisted tunneling (MTAT) model 114
- Multiple-nanowire devices 336
- Nano size effects, on oxide ion conductor films 206–8
- Nanolithographic tools 334
- Nanoporosity 89–94
- Nanoporous titanium oxide layers, slow release capacity of 321–22
- Nanopowders 58
- Nanostructural features, of EC films 233–34
- Nanotubular TiO₂ surfaces 317
- Nanowire and nanobelt
 - crystalline orientation for 332
 - growth process for 332
- Neodymium-doped yttrium aluminum garnets (Nd:YAG) 239
- Ni(II) passive films 133–35
- Nickel 123–24
- Nickel nanoparticles, self-organized growth of 56
- Nickel oxide
 - growth behavior of 67
- NiO/FeO(001), case study 39–40
- NiO nanolayer 59
- Nitrogen dioxide, adsorption of 341
- Noncontact atomic force microscopy (NC-AFM) 28, 30–31
- Novel structure concepts 49–58
- One-dimensional heterostructures 332
- One-dimensional oxide systems 58, 60–61
- Open-circuit voltage (OCV) 212
- Optical gas sensors 248–49
 - basic principles of 248
- Optical sensors 340–41
- Ordered oxide nanostructures on metal surfaces 47–69

- fabrication 48–49
- from two- to one- to zero-dimensional structures 58–63
- novel structure concepts 49–58
- transition from two- to three-dimensional structures 63–68
- Osteoconductivity 319
- Oxidation of Rh(111), case study 34–35
- Oxidative nanopatterning 314, 318
 - with $\text{H}_2\text{SO}_4/\text{H}_2\text{O}_2$ 320
- “oxide electronics” 182
- Oxide films as catalytic materials and models of real catalysts 145–74
 - growing as supports 146–54
 - models 154–66
 - ultrathin-film catalysts 166–73
- Oxide films as molecular and atomic sieves 89–94
- Oxide heterostructures, electric control of magnetization in 189–97
 - LSMO films, proximity and electric field effects on magnetic properties of 189–96
 - magnetoelectric coupling at Fe–BTO interfaces 196–97
- Oxide ion conductor thin films preparation 203–6
- Oxide MLs 95
- Oxide nanolayers, electronic properties of 59
- Oxide nanosheets and buried layers 19–21
 - buried oxide layers 20–21
 - detachable ultrathin oxide films 19–20
 - exfoliated oxide nanosheets 19
- Oxide passive films and corrosion protection 119–41
 - on chromium 124
 - on copper 122–23
 - corrosion modeling by DFT 137–40
 - electrochemical fundamentals of passivation of metals 119–22
 - growth and nanostructure of three-dimensional ultrathin oxide films 130–37
 - – Cr(III)-rich passive films, aging effects on 136–37
 - – Cu(I) and Cu(I)/Cu(II) passive films 131–33
 - – Fe(II)/Fe(III) passive films 135–36
 - – Ni(II) passive films 133–35
 - on iron 124
 - on nickel 123–24
 - on silver 123
 - on stainless steel 124–26
 - two-dimensional oxide passive films on metals 126–30
 - – copper 126–28
 - – silver 128–30
- Oxide targets, sputtering and ablation of 8–9
 - pulsed laser deposition (PLD) method 8–9
 - sputter deposition 8
- Oxide–metal hybrid systems 47, 48
- Oxide–metal interface 49, 53, 56
- Oxide-on-metal nanostructures 69
- Oxides at the nanoscale 75
- Oxides on oxides 163–66
- Oxygen-deficient defect centers, in bulk HfO_2 , 106–7
- Oxygen vacancies
 - and optical sensors 340
- Palladium deposits on MgO 168
- Palladium, potential energy profiles for 90–91
- Pb(Zr,Ti)O₃ films 8
- Pertsev phase diagram 278
- pH response and metal oxides 247
- Phonon spectrum 60
- Phosphonates 316
- Photochromics 223
- Photodetectors and detectors, for (F)IR region 246
- Photoelectron diffraction 35–36
 - VO layers on TiO₂(110), case study 36
- Photoelectron spectroscopy (PES) 27
- Physical methods of preparation of oxide ultrathin films 7–14
 - controlled oxidation of bulk single-crystal surfaces 7–8
 - pre-deposited thin metal films, post-oxidation of 13–14
 - reactive physical vapor deposition 9–13
 - – film growth by reactive MBE 10–13
 - – film growth by sputtering or ablation of pure targets in oxidizing atmosphere 10
 - sputtering and ablation of oxide targets 8–9
 - – pulsed laser deposition (PLD) method 8–9
 - – sputter deposition 8
- Physical vapor deposition (PVD) 9–13, 48, 49
- Physisorption 250
- Piezoelectric materials 265
- Platinum particles on Fe₃O₄ 171
- Point defect model 314
- Polarity compensation mechanisms 56–58
- “Polarization–strain” coupling 278
- Polaronic distortion 167
 - and oxide thin films 94–97
- Poly(ethylene terephthalate) (PET) 232

- Polycrystalline gate oxide films 110–14
 - defect segregation at grain boundaries 113–14
 - on microelectronic device characteristics 110–12
 - structure and electronic properties of grain boundaries 112–13
- Polymer electrolyte fuel cell (PEFC) 201
- Porous nickel 205
- Post-oxidation (PO) method 48
- Pre-deposited thin metal films, post-oxidation of 13–14
- Protein adsorption 317
- Pulsed laser deposition (PLD) method 8–9, 1–21, 49, 182, 205
- Pyroelectric materials 265
- Quartz-based sensors 249–50
- Quasi one-dimensional nanostructures 330, 331
 - synthesis of 331–34
- Quenching effects 340–41
- Radio frequency magnetron sputtering 8
- Reactive evaporation (RE) method 48
- Reactive MBE, film growth by 10–13
- Reactive physical vapor deposition 1–21
 - film growth by reactive MBE 10–13
 - film growth by sputtering or ablation of pure targets in oxidizing atmosphere 10
- Reactive-layer-assisted deposition (RLAD) 49
- Real catalysts, model of 154–66
 - oxides on oxides 163–66
 - supported gold 154–63
- Relaxation–charge relationship 96
- Rh(111), oxidation of
 - case study 34–35
- Samarium-doped ceria (SDC20) 210
- Scanned probe microscopy (SPM) 28
- Scanning electron microscopy (SEM) 205
- Scanning tunneling microscopy (STM) 28–30, 80–81
 - CeO₂(111)/Pt(111), case study 30
- Schottky model 85
- Second-principle methods, in ferroelectricity theoretical methods
- Self-trapped polarons, in HfO₂, 107–8
- Sensor applications, oxide ultrathin films in 239–60
 - electrochemical sensors 246–47
 - gas sensors 247–54
 - magnetic sensors 243–46
 - photodetectors and detectors for (F)IR region 246
 - SnO₂-based gas sensors 254–58
- Sensor applications, ultrathin oxide materials for 241
- Shell model 273
- Si/SiO₂/HfO₂ films and interfaces 109–10
- Silanes 316
- Silica and high-*k* dielectric thin films, in microelectronics 101–14
 - electrical characterization of 103–4
 - models of structure and properties of HfO₂ gate dielectric films 106–10
 - polycrystalline gate oxide films 110–14
 - theoretical modeling of gate dielectric films 104–6
- Silicon 205
- Silicon dioxide films 75
- Silicon-based microelectronic devices 240
- Silver 123, 128–30
- Single nanowire-based devices 336
- Single-crystalline metal oxides 330
- Single-crystalline oxide nanowires 329
- SiO₂/Mo film 50
- SiO₂ ultrathin film on MO surface 87
- SiO₂/Mo film 51
- Sm(Sr)CoO₃ (SSC) 212
- SnO₂ 17
- SnO₂-based gas sensor devices 254–58
- SnO₂-based gas sensors 253–54, 254–58
 - sensor fabrication 254–55
 - sensor performance 255–58
- μ-SOFCs 217, 219
 - development of 216–17
 - structure and power generation property of 218
- “Solar control” coating 222
- Solar energy materials 221–36
 - electrochromics 232–35
 - EC foils by roll-to-roll manufacturing 234–35
 - nanostructural features, of EC films 233–34
 - thermochromics 228–32
 - magnesium doping of VO₂, 231–32
 - VO₂ films and nanoparticles 229–31
 - transparent infrared reflectors and transparent electrical conductors 223–28
 - alternative transparent conductors 226–28
 - computed optical data, for ITO films 225–26
- Sol–gel process 17
- Solid oxide fuel cells (SOFCs) 201–19, 201–3
 - μ-SOFCs, development of 216–17
 - advantages of 201

- nano size effects on 206–8
- oxide ion conductor thin films preparation 203–6
- power generating property of
 - using LaGaO₃ thin films 208–16
- techniques used for 204
- typical structure of 202
- Spectral selectivity 221
- Spectroscopic techniques 36–43
 - conversion electron Mössbauer spectroscopy (CEMS) 41–43
 - Fe₃O₄(111)/Pt(111), case study 43
 - magneto-optical Kerr effect
 - Fe/NiO/MgO(001) and Fe/NiO/Ag(001), case study 40–41
 - magneto-optical Kerr effect (MOKE) 40–41
 - X-ray magnetic circular/linear dichroism 36–40
 - Fe_{3- δ} O₄(111) ultrathin films on Pt(111), case study 38–39
 - NiO/FeO(001), case study 39–40
- Spin polarization analysis by Mott scattering (SPMS) 188
- Spin polarized inverse photoemission (SPIPE) 185
- Spin polarized photoemission spectroscopy (SPES) 182
- Spintronics, oxide films in 181–97
 - electric control of magnetization in oxide heterostructures 189–97
 - LSMO films, proximity and electric field effects on magnetic properties of 189–96
 - magnetoelectric coupling at Fe–BTO interfaces 196–97
 - half-metallic manganites 183–89
 - historical notes 182–83
- Spray deposition methods 16
- Spray pyrolysis 16, 17
- Sputter deposition 8
- Sputtering 205
- Stainless steel 124–26
- STEM with electron energy loss spectroscopy (STEM-EELS) 192
- Strain 277–80
- Strong metal support interaction (SMSI) model 170
- Strontium titanate films 13
- Structural flexibility 94–97
- Structure determination techniques 28–36
 - noncontact atomic force microscopy (NC-AFM) 30–31
 - photoelectron diffraction 35–36
 - VO layers on TiO₂(110), case study 36
 - scanned probe microscopy (SPM) 28
 - scanning tunneling microscopy 28–30
 - CeO₂(111)/Pt(111), case study 30
 - surface X-ray diffraction (SXRD) 33–35
 - oxidation of Rh(111), case study 34–35
 - X-ray photoemission electron microscopy (X-PEEM) 31–33
 - iron oxide on α -Al₂O₃(0001), case study 33
 - Structure–property relationship 49
 - Substrate oxidation 4
 - Superconducting quantum interference device (SQUID) 245–46
 - Surface oxide layer, strategies for modification of 311–16
 - biochemical functionalization 315–16
 - chemical methods 312–15
 - doping of oxide layers with bioactive elements 314–15
 - oxide growth models for oxidative treatments 313–14
 - physical methods 315
 - Surface relaxation 87
 - Surface selection rule 60
 - Surface topography 317
 - Surface X-ray diffraction (SXRD) 33–35
 - oxidation of Rh(111), case study 34–35
 - Synthesis and preparation of oxide ultrathin films 1–21
 - chemical methods 14–19
 - chemical vapor deposition 15–16
 - liquid-precursor-based thin-film deposition techniques 16–19
 - fabrication, basic aspects of 3–7
 - oxide nanosheets and buried layers 19–21
 - buried oxide layers 20–21
 - detachable ultrathin oxide films 19–20
 - exfoliated oxide nanosheets 19
 - physical methods 7–14
 - controlled oxidation of bulk single-crystal surfaces 7–8
 - pre-deposited thin metal films, post-oxidation of 13–14
 - reactive physical vapor deposition 9–13
 - sputtering and ablation of oxide targets 8–9
 - Thermochromics 223, 228–32, 228–29
 - magnesium doping of VO₂, 231–32
 - VO₂ films and nanoparticles 229–31
 - Thin MgO, gold deposits on 161
 - Thomas–Fermi model 286
 - Tin oxide 254

- TiO₂(110), VO layers on
 - case study 36
- Titania thin films 309–24
 - advent of titanium-based materials 309–10
 - biological surface science 316–17
 - biologically relevant physicochemical properties of 310–11
 - nanoporous titanium oxide layers, low release capacity of 321–22
 - surface oxide layer, strategies for modification of 311–16
 - biochemical functionalization 315–16
 - chemical methods 312–15, 313–14
 - physical methods 315
 - surface oxide layers, biological response to 317–21
 - antibacterial capacity 320–21
 - *in vitro* studies 317–19
 - *in vivo* and clinical studies 319–20
 - protein adsorption 317
- Titanium dioxide 311
- Titanium dopant ions 108
- Titanium oxide films 12
- Top-down technique 331
- Top-gated FEDs 195
- Transition metal oxides 11
- Transparent conducting oxides (TCOs) 223
- Transparent infrared reflectors and transparent electrical conductors 223–28, 223–25
 - alternative transparent conductors 226–28
 - computed optical data, for ITO films 225–26
- Tunnel magnetoresistive (TMR) sensors 183, 243, 244
- Two-dimensional to one-dimensional to (quasi-)zero-dimensional structures 58–63
- Two-dimensional to three-dimensional transition 63–68

- Ultra-high vacuum (UHV) 28
- Ultrathin silica films, nanoporosity of 91
- Ultrathin-film catalysts 166–73
- “Urbach tails” 224

- V₂O₃ structure on Pd surface 50–52 52
- V₃₆O₅₄ structure on Rh surface 52
- Vacancy-induced self-doping effect 55

- Vanadia nanoparticles on ceria 163–66
- Vanadium dioxide 228
- Vanadium oxide 123
 - on Rh surface 52
- Vanadium oxide films 11
- Vanadium pentoxide (V₂O₅) films, growth of 66–67
- Vanadium trioxide (V₂O₃) films, growth of 64–66
- Vertically aligned nanocomposite (VAN) 214
- VO layers on TiO₂(110), case study 36
- VO₂ films and nanoparticles
 - *T*_{sol}, modulation of 229–31

- Water chemisorption 335
- Wentzel–Kramers–Brillouin approximation 30
- (WO₃)₃ clusters 63
- Work function changes 85–89
- Work functions of metal and oxide thin films on metals 86

- X-ray absorption spectroscopy (XAS) 33
- X-ray magnetic circular dichroism (XMCD) 36–40, 188
- X-ray magnetic circular/linear dichroism
 - Fe_{3–δ}O₄(111) ultrathin films on Pt(111), case study 38–39
 - NiO/FeO(001), case study 39–40
- X-ray magnetic linear dichroism (XMLD) 36–40
- X-ray photoelectron diffraction (XPD) 35, 36
- X-ray photoelectron spectroscopy (XPS) 27, 122
- X-ray photoemission electron microscopy
 - iron oxide on α -Al₂O₃(0001), case study 33
- X-ray photoemission electron microscopy (X-PEEM) 31–33

- Y₂O₃-stabilized ZrO₂ (YSZ) 203, 210
- Yttrium barium copper oxide (YBCO) 239

- Zero-dimensional oxide nanostructures 58
- Zinc oxide on Pd surface 57
- Zirconia 106
- ZnO on Pd surface 57
- ZnO polycrystalline films 17